

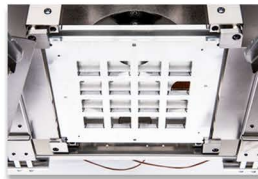
# Masking Shutter

## Boost Efficiency and Productivity

Controlled exposure of single or multiple rows and/or columns within a sample matrix, which is then rotated allowing for unique films on each cell.

Conditions will subtly change from deposition run to deposition run. This fixture allows you to create multiple samples, under identical conditions, in a single run.

**Capable of creating gradient and stepped films across a single, larger substrate.**



**Add this fixture to most of our standard and custom system architectures.**



Our team of engineers, chemists, and nanotechnologists will help design the best tool for your process and material requirements. We offer support and can optimize your system for film thickness uniformity, film structure and material utilization. Please call us to discuss your application in detail.

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